

Recent Light Extraction Development in OLED

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Outcoupling Efficiency (χ_{out})

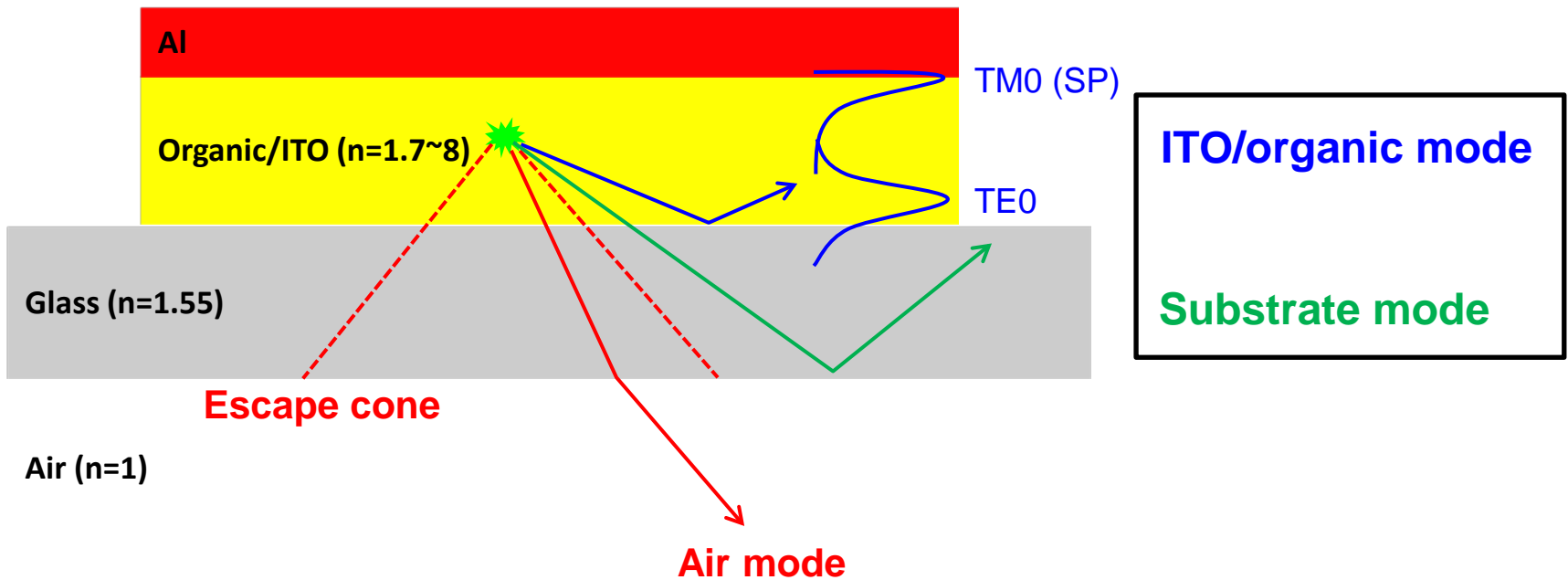
◆ Internal quantum efficiency (η_{int}) : ~ 100%

◆ External quantum efficiency (η_{ext}) : ~25%

- ITO/organic waveguide mode : ~50%
- Substrate mode : ~25%
- **Air(outcoupled) mode : ~25%**

$$\eta_{\text{ext}} = \chi_{\text{out}} \eta_{\text{int}}$$

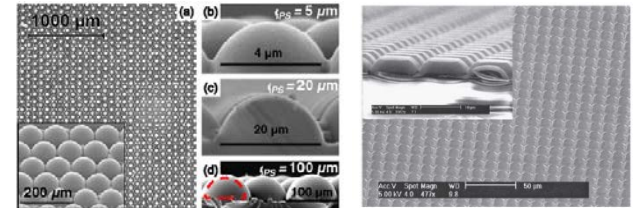
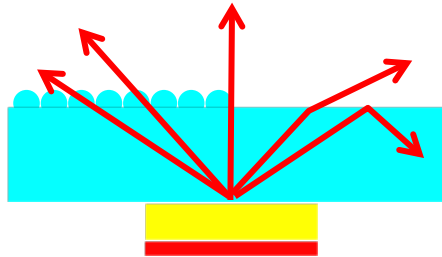
$\chi_{\text{out}} : \sim 25\%$



Outcoupling for substrate mode

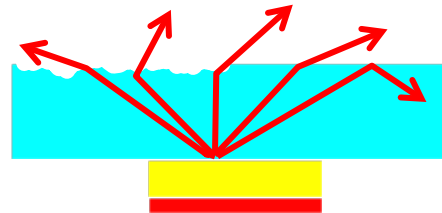
◆ Outcoupling techniques

- Microlens array

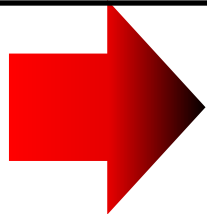


Möller, J. Appl. Phys. 91 (2002)

- Substrate roughening



Chen, Opt. Express 18, 37 (2010)



***1.5~1.8 times enhancement with convenient
and low cost fabrication***

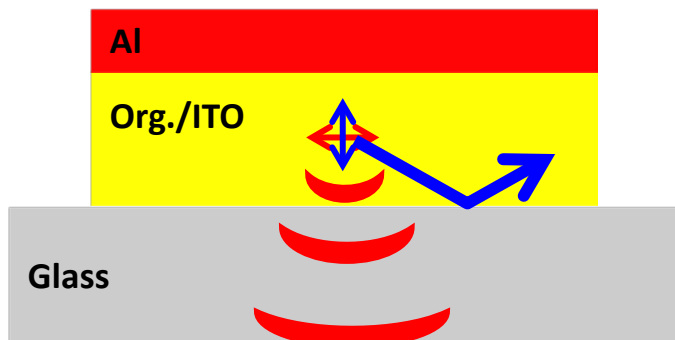
Out-coupling for thin film guided mode

Other concepts of outcoupling techniques

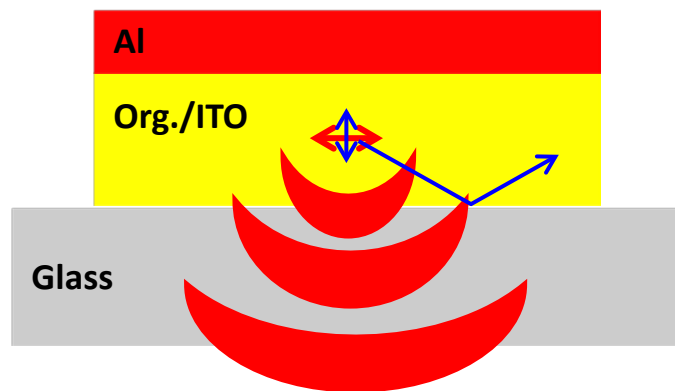
◆ Horizontally oriented emitter

- Isotropic dipoles

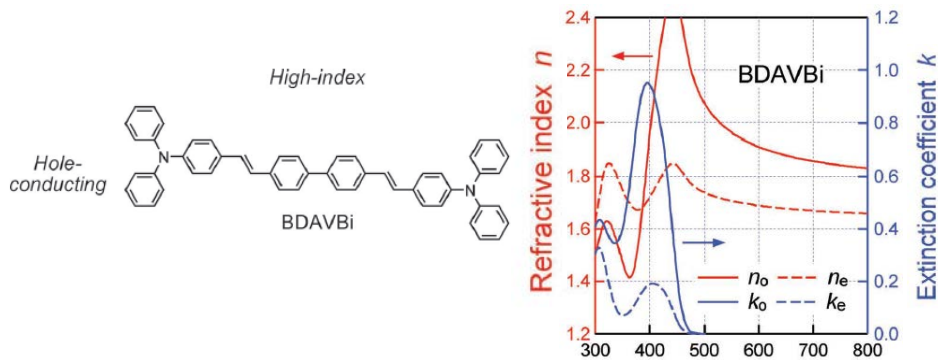
↕ vertical ↔ horizontal



- Horizontally-oriented dipoles

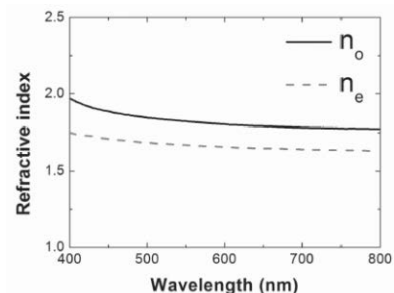


- D. Yokoyama et al, Adv. Funct. Mater. 24 (2012)



➡ More horizontally-oriented materials

- Kim et al, Adv. Funct. Mater. 23 (2013)

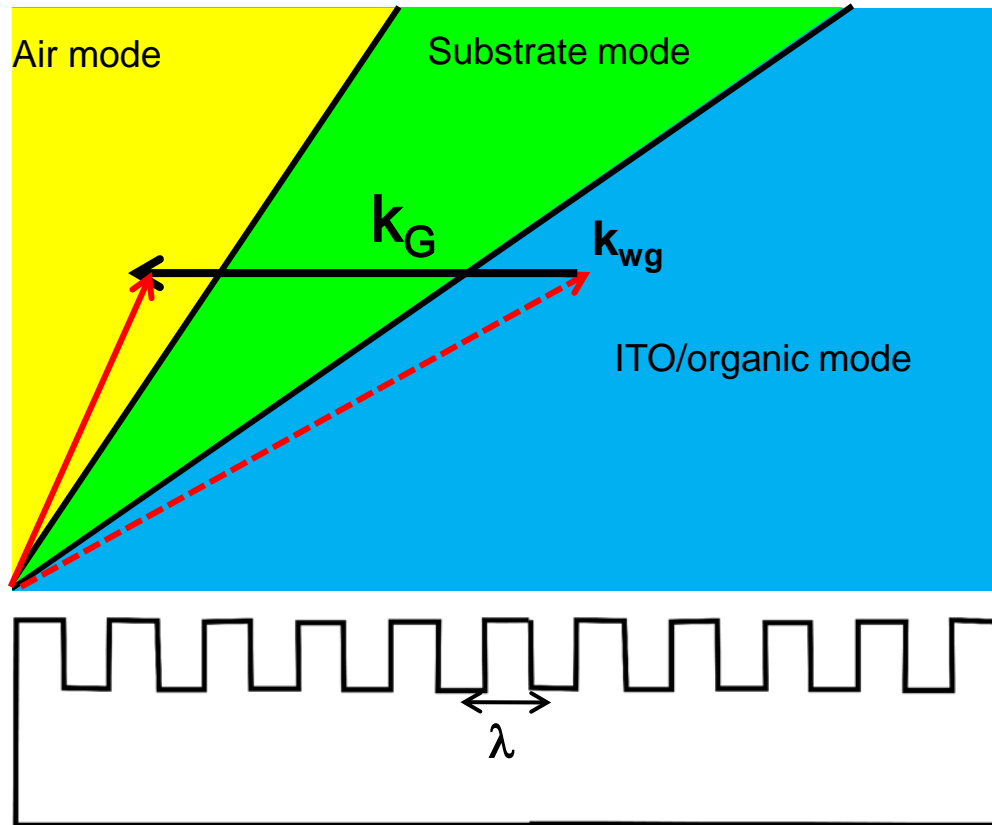


➡ Horizontally oriented emitters by **non-isotropic matrix of B3PYMPM** in emitting layer

➡ Exceeding EQE of 30%

Outcoupling for wave-guided mode :Corrugated OLEDs

◆ Schematic dispersion curve in OLED



◆ Diffraction grating equation

$$k_{//} = k_o \sin \theta = k_{wg} \pm m k_G$$

$$k_G = 2\pi / \lambda_G$$

k_o : wavevector in free space

$k_{//}$: wavevector of in-plane component of k_o

θ : angle of emitted light with respect to the surface normal

k_G : wavevector of grating

M : integer

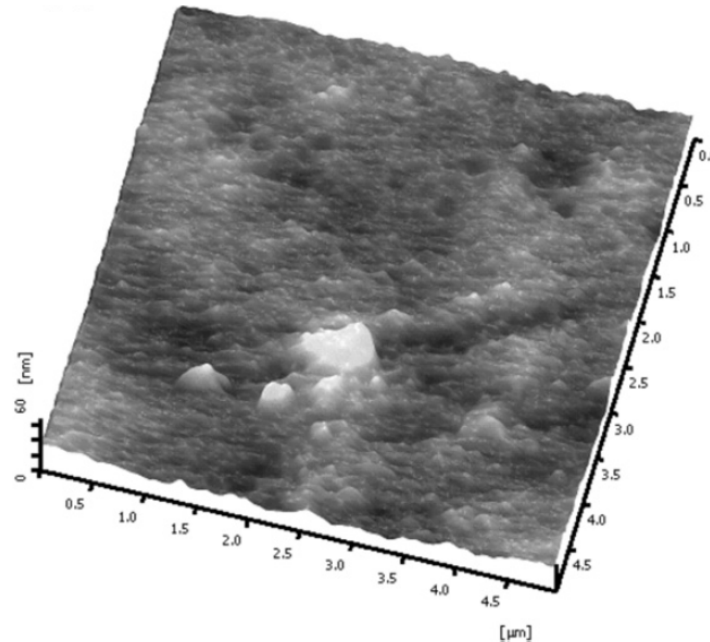
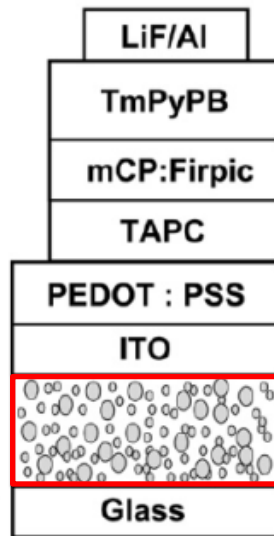
λ_g : period of grating

- Key to control grating vector/periodicity of the grating structure
- 0.3~ 1 μm periodicity with 40~100 nm of depth

Outcoupling for wave-guided mode

◆ Internal scattering layer

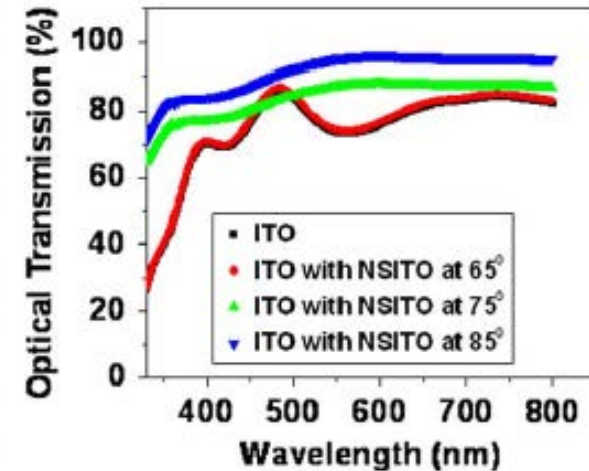
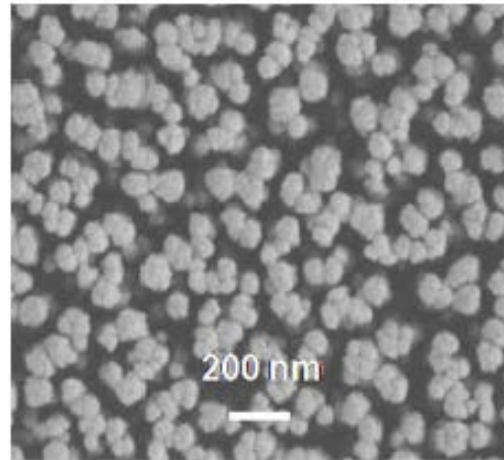
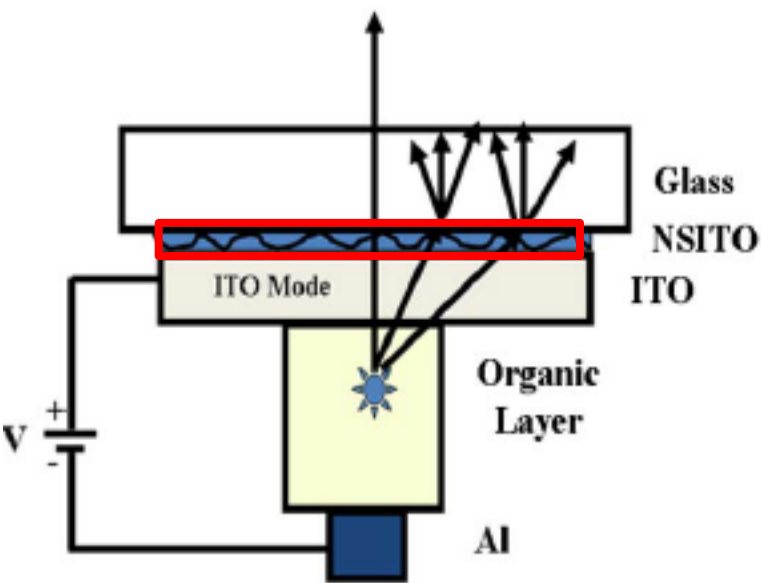
- C. Chang et al, Org. Electron.13, 1073 (2012)



- Scattering layer : : transparent photoresist ($n=1.52$) + TiO_2 particles
 - ➡ refractive index : $n=1.5\sim1.9$
 - ➡ still high transparent $\sim 85\%$
 - ➡ 2 times enhancement in EQE

Outcoupling for wave-guided mode

◆ Scattering ITO layer - A. Kumar et al, Opt. Lett. 37 (2012)



• Scattering porous nanostructured ITO

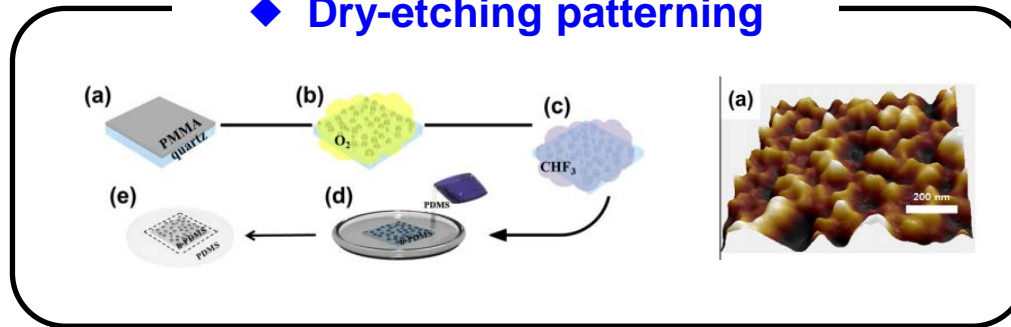
➡ Glancing angle deposition method by RF sputter

1. Scattering media formed by porous/n-ITO particles
2. Index varies from 1.2-1.9 depending on the deposition angle
3. 80% enhancement in light output

Other similar works – different fabrication methods

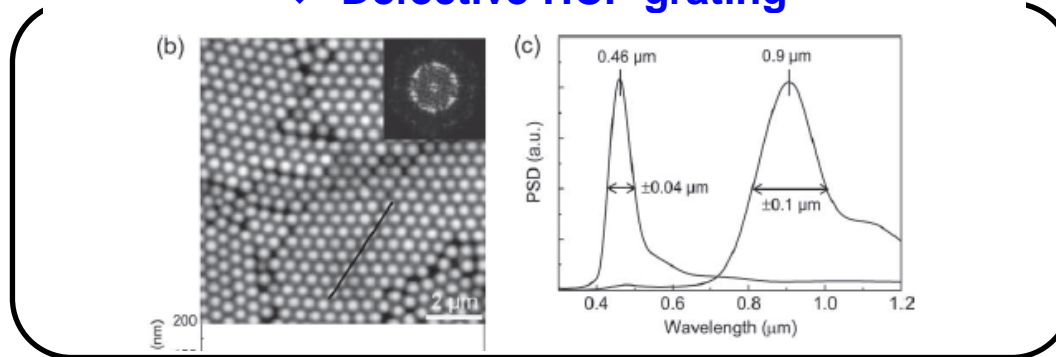
- S. Shin et al, Org. electron. 14 (2013)

◆ Dry-etching patterning



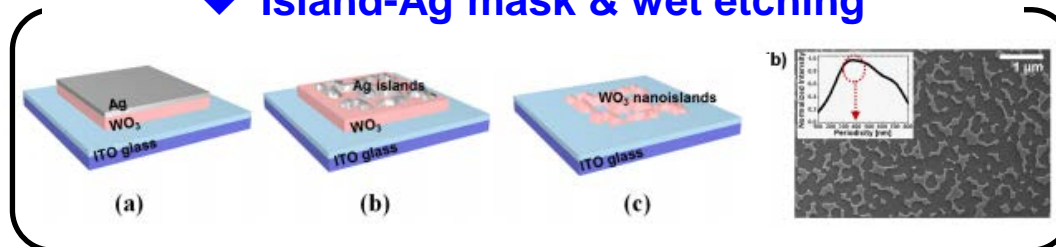
- W. Koo et al, Adv. Funct. Mater. 22 (2012)

◆ Defective HCP grating



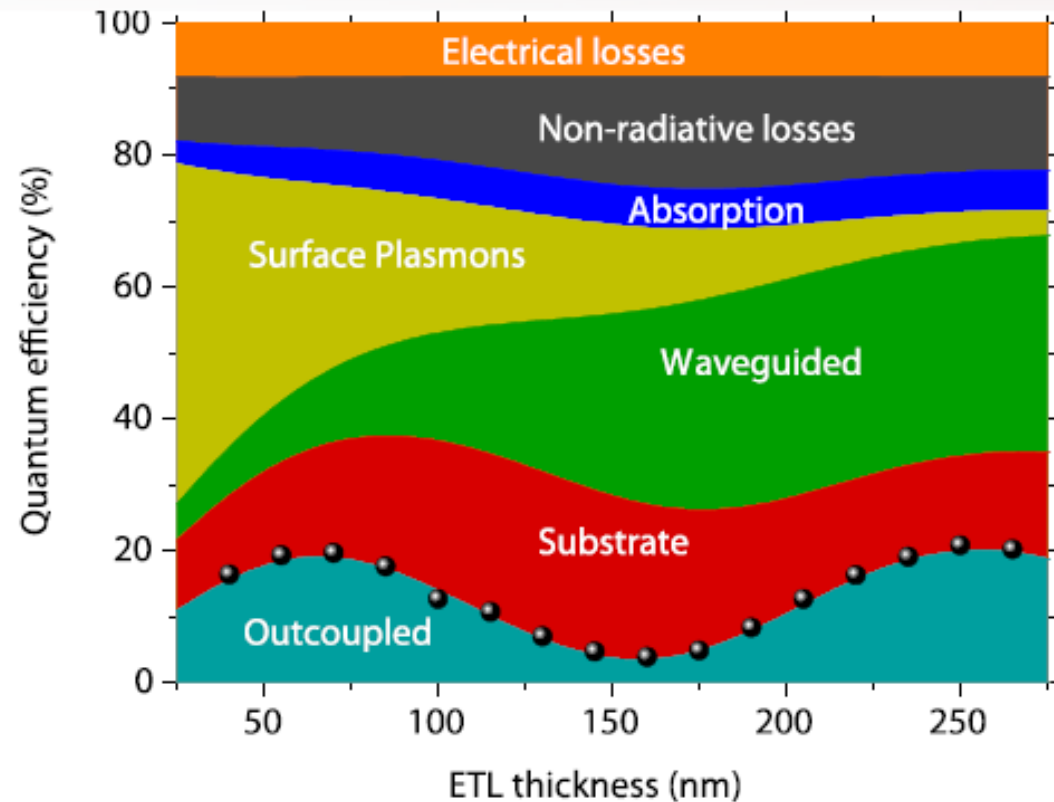
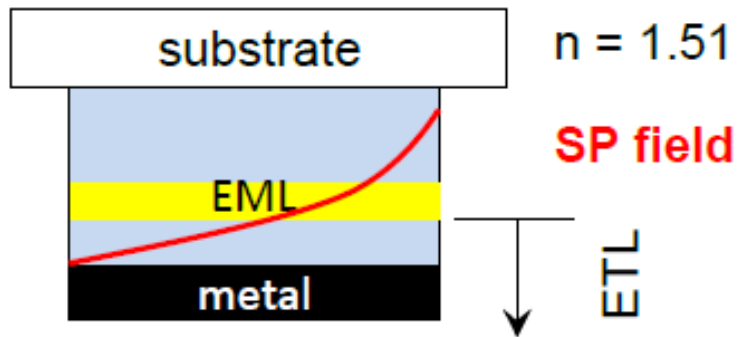
- J. Kim, Opt. Express. 5 (2013)

◆ Island-Ag mask & wet etching



Optical modes – device structure dependence

[Appl. Phys. Lett. 97, 253305 \(2010\)](#)

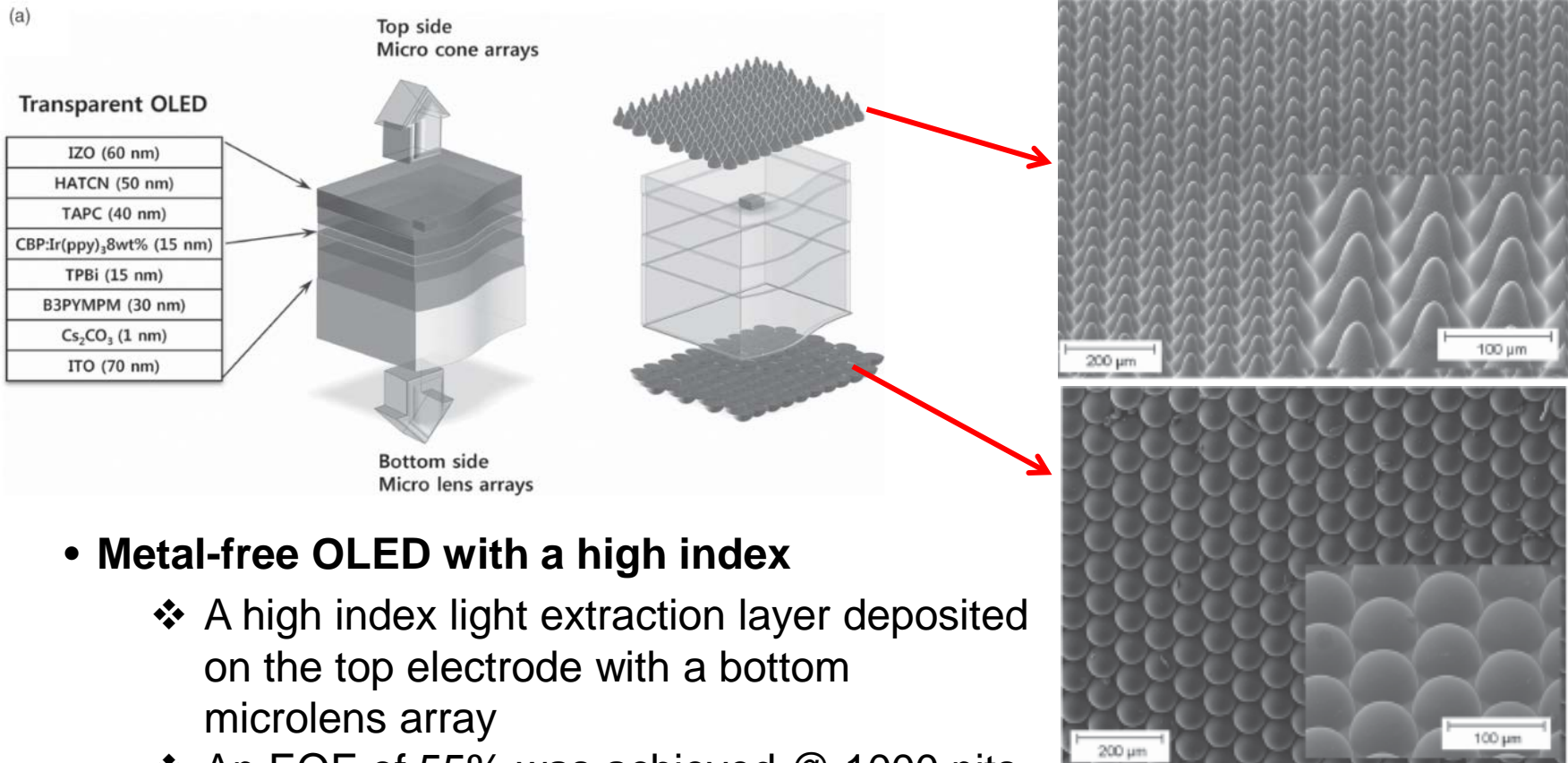


Other concepts of outcoupling techniques

◆ Metal-free both side transparent electrodes

- Kim et al, Adv. Mater. 25, 3571 (2013)

Structure & SEM of electrodes



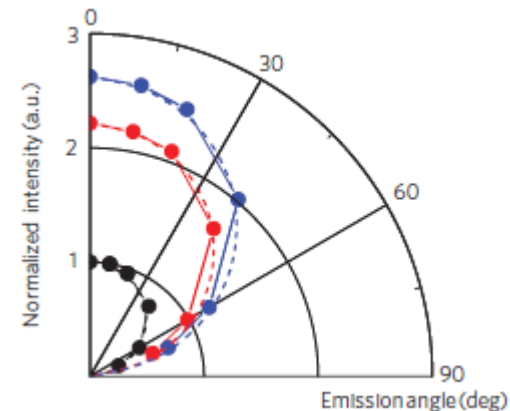
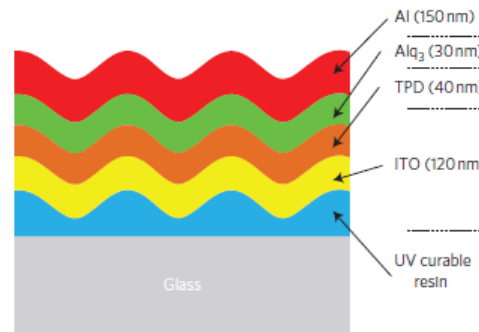
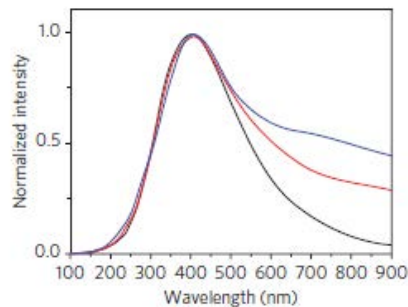
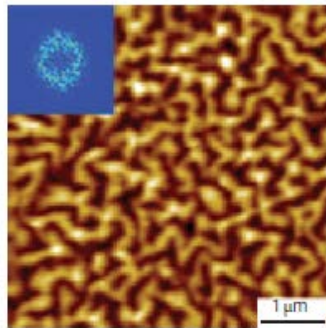
- **Metal-free OLED with a high index**

- ❖ A high index light extraction layer deposited on the top electrode with a bottom microlens array
- ❖ An EQE of 55% was achieved @ 1000 nits

Outcoupling for wave-guided mode :Corrugated OLEDs

◆ OLED on buckle structure

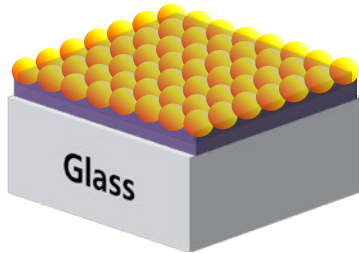
- W. Koo, Nature photonics 21 (2010)
- Grating structures with **broad distribution of periodicity**
 1. All wavelength extraction met by Bragg diffraction law
 2. Still close-Lambertian distribution
 3. 2.2 times enhancement in current efficiency



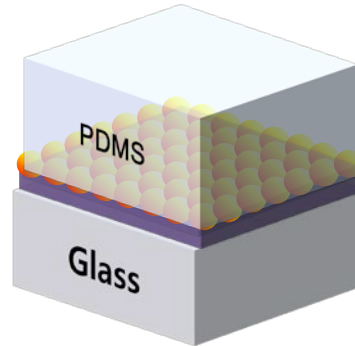
Corrugated structure fabrication

Template

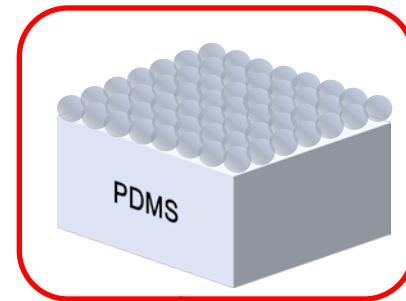
Silica sphere template



Replica

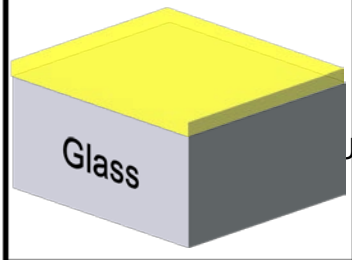


Mold



Spincoating

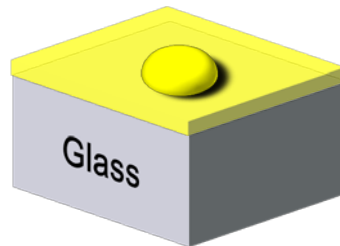
UV-curable resin



UV-curing

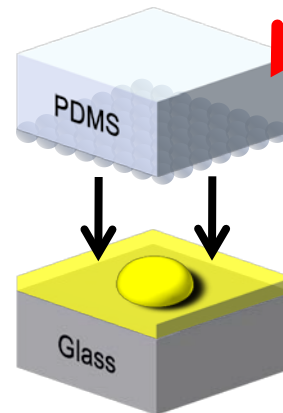
Drop

UV-curable resin



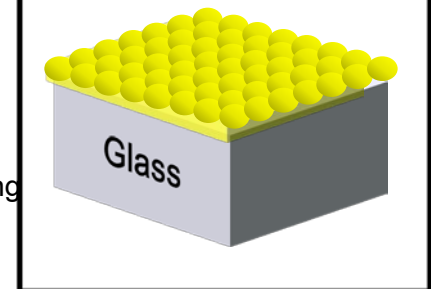
Imprinting

Silica PDMS replica



UV-curing

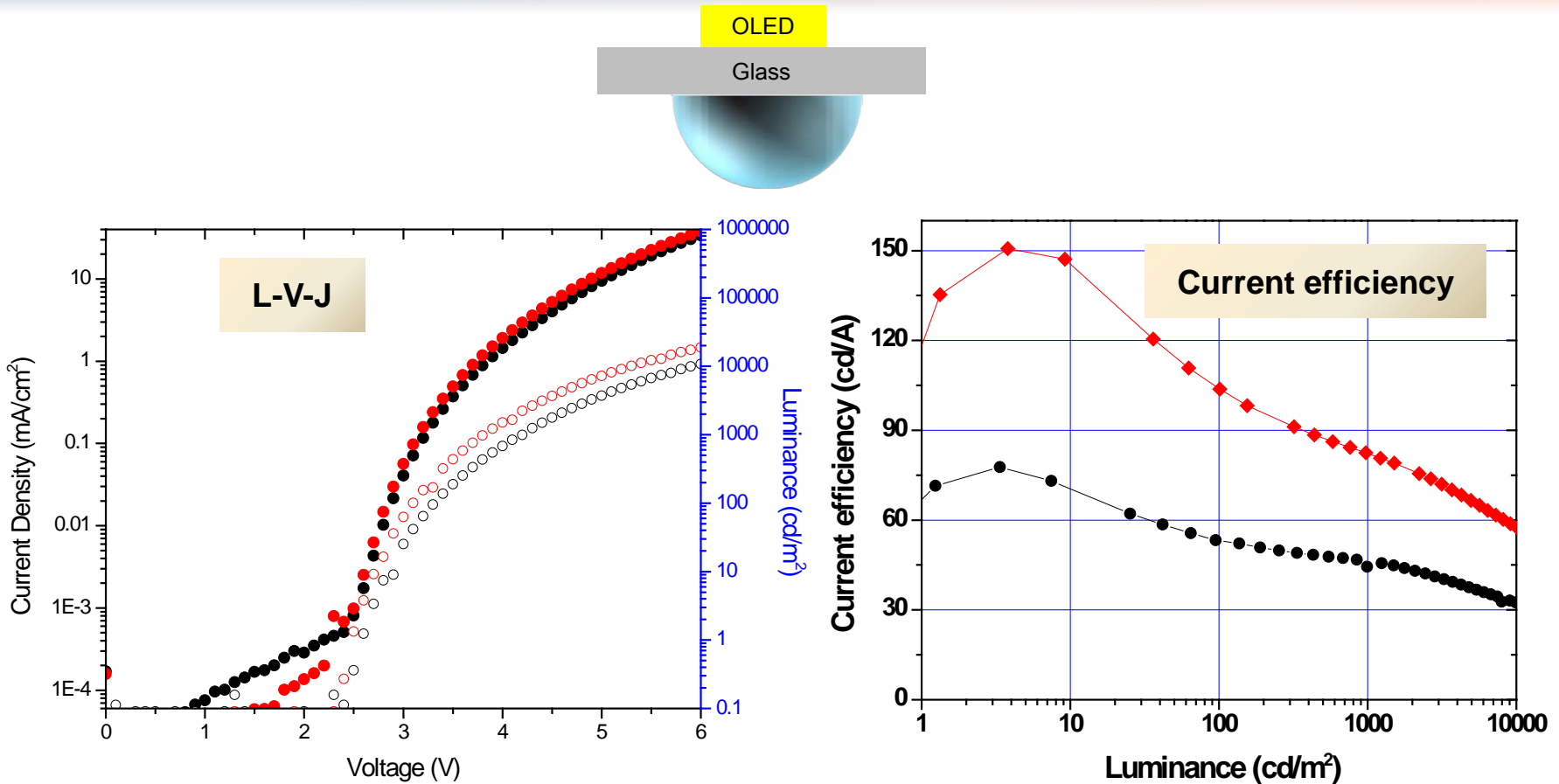
Peel-off



Flat OLED (ref. device)

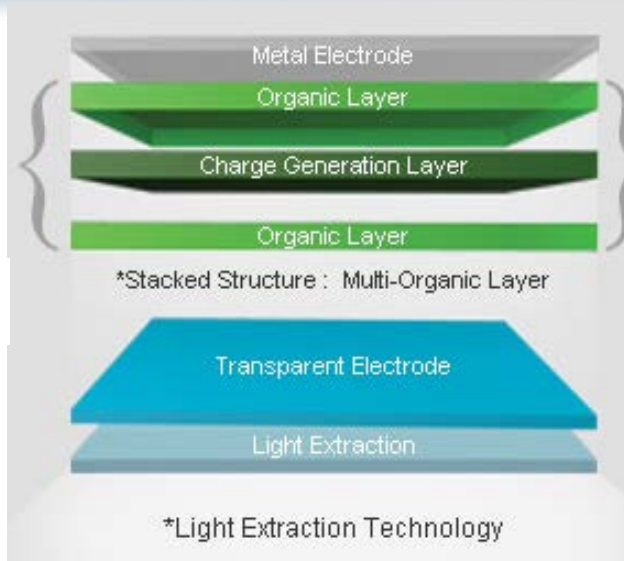
Grating OLED

High efficiency Irppy₃ devices w/ grating



- Grating : 74 cd/A and Ref : 48 cd/A at 2000 cd/m²
 - **55% enhancement** in current efficiency
 - ✓ At low luminance, current efficiency is more than 2X enhanced

Latest OLED lighting product development



- Commercial 80 lm/W OLED with outcoupling for waveguide mode in 2013

<http://www.lgchem.com/global/green-energy/oled-lighting>

Panasonic



Figure: Panasonic - High efficiency white OLED

- 114 lm/W OLED in 2013
- **Built-up Light Extraction Substrate (BLES)**
50% EQE

<http://www.osadirect.com/news/article/970/>

Going forward....

- EQE approaching 70% is possible
- Low-cost manufacturing light extraction schemes are needed for SSL

Thank you for your attention